## **Synthesis and Crystal Structure of 9,lO-Disilatriptycenes**

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9,lO-Disilatriptycenes **la-lc** have been synthesized by a novel route *via* **o-trimethylsilylphenyllithium,** a novel synthetic equivalent of o-halogenophenyl anion; the structure of the 9-methyl-10-hydroxy derivative **lc** was determined by X-ray crystallography.

Triptycenes have been investigated extensively because of their unique structures,<sup>1</sup> whereas heterotriptycenes in which bridgehead (9 and/or 10) positions are substituted by group 14 and 15 elements of the third or higher row have received much less attention. The sole known example of a heterotriptycene having a heavier group 14 element is a disilatriptycene derivative with tetrafluorinated  $o$ -phenylene vanes.<sup>2</sup> While the present work was in progress, the formation of la in the co-pyrolysis of **5,10-dihydro-5,10-silaanthrene** and o-dichlorobenzene was reported by a Russian group.<sup>3</sup> It is difficult to obtain a reasonable amount of la by this reaction however.

The paucity of examples of disilatriptycenes is mainly due to

the difficulty in preparing suitable precursors. We report here a general and efficient synthetic route to 9,lO-disilatriptycenes **1** *via* a key intermediate, **o-trimethylsilylphenyllithium 2,**  which is applicable to the synthesis of other heterotriptycenes as well. We also describe the first X-ray crystallographic analysis of a 9,lO-disilatriptycene derivative.

Although the reaction of trichlorosilane and o-iodophenyl anion seems to be a reasonable route to **4,** a logical precursor of **1,** it is impractical in fact, because of the high propensity of o-halogenophenyl anions to form benzyne. We have found that o-trimethylsilylphenyl anion **2** can serve as an efficient synthetic equivalent of  $o$ -iodophenyl anion by taking advan-





tage of the fact that a trimethylsilyl group is readily transformed into a halogeno group by treatment with halogens4 (Scheme 1).

The reaction of **1-bromo-2-trimethylsilylbenzene5** with 1 equivalent of lithium dispersion in refluxing diethyl ether for 30 min afforded an ethereal solution of o-trimethylsilylphenyllithium **2.** When the solution of **2** (90.0 mmol) was added to an ethereal solution of trichlorosilane (15.0 mmol) and the resulting solution was stirred at room temperature for 20 h, **tris(o-trimethylsily1phenyl)silane** 3 was obtained in 88% yield. Treatment of 3 (16.3 mmol) with iodine monochloride (48.8 mmol) in dichloromethane at  $0^{\circ}$ C for 2 h afforded tris(oiodopheny1)silane **4** in high yield (91%).

Lithiation of **4** (10.0 mmol) with tert-butyllithium (63.0 mmol) at  $-78$  °C in diethyl ether-benzene (3:1) gave trianion **5** cleanly as shown by deuteriation experiment with  $D_2O$ . The reaction of 5 with trichloromethylsilane at  $-78$  °C for 2 h followed by slow warming of the reaction mixture to room temperature afforded **5,10-dihydro-5-methy1-5,10[** 1' ,2']-benzenosilaanthrene **lb,** which was purified by chromatography on silica gel followed by recrystallization from cyclohexane or hexane (16%). Similar reaction of **5** with trichlorosilane gave **la** (11%). Although **la** is decomposed on silica gel, it was purified by direct recrystallization of the crude product from hexane. Both **la** and lb were obtained as colourless cubic crystals and their structures were confirmed by spectroscopic data (NMR, UV, and MS) and elemental analyses.<sup>†</sup>



**Fig. 1** ORTEP drawing of 9,lO-disilatriptycene **lc** 

**1H** NMR signals at **6 CQ.** *5.5* for **la** and **lb** flanked by symmetric satellites are assignable to Si-H and the chemical shift is close to that of triphenylsilane (6 5.47). The **lH** NMR signal due to the methyl group of 1b  $(\delta 1.10)$  appeared at lower fields than that of methyltriphenylsilane  $6$  ( $\delta$  0.87), whereas the <sup>13</sup>C NMR signal of the methyl carbon of **1b**  $(\delta -13.4)$ shifted to higher field by about 10 ppm compared to 6 ( $\delta$ -3.4). Similar changes in **1H** and 13C NMR chemical shifts of the methyl groups were observed in the case of  $1,1,1$ triphenylethane  $7$  and 9-methyltriptycene 8 (7:  $\delta_H$  2.19,  $\delta_C$ 30.5; **8: bH** 2.36, *bC* 13.2). 2% NMR signals of **lb** appeared at  $\delta_{Si}$  –43 and –52, at substantially higher field than those of triphenylsilanes (Ph<sub>3</sub>SiMe:  $\delta_{Si}$  - 8, Ph<sub>3</sub>SiH:  $\delta_{Si}$  - 21).<sup>6</sup> It is also interesting that the weak absorptions at 270 nm in the UV spectrum of triptycene shifted to slightly longer wavelength for **la** and lb **(la:** 286 nm, **lb:** 284 nm), suggesting a possible increase of inter-vane charge transfer interaction compared to triptycenes.<sup>7</sup>

For X-ray structural analysis, **lb** was converted to the hydroxy compound **lc** by the reaction with IC1 followed by hydrolysis (Scheme 2). Recrystallization from hexane gave single crystals of 1c $\cdot$ 0.5H<sub>2</sub>O, the molecular structure of which was determined by X-ray crystallographic analysis (Fig. 1). $\ddagger$ 

The triptycene skeleton of **lc** has a slightly squashed shape with the silicon atoms closer compared with normal aromatic ortho-substituted atoms. The bond angles subtended at the bridgehead Si atoms  $[C(1)-Si(1)-C(12)$  etc.] are 102.1-105.5°, being less than the usual tetrahedral value of 109.5°, and 1–2° smaller than those of triptycene derivatives  $(104.0-106.5^{\circ})$ .<sup>8</sup> The external  $[Si(1)-C(1)-C(2)$  etc.] and internal  $[Si(1)-C(1)-C(1)]$  $C(6)$  etc.] angles of the disilabicyclooctane rings are 125.2-127.0 and 113.6-115.9", respectively, substantially different from 120° [triptycenes: 125.0–127.4° (external), 112.1–114.5°  $(internal)$ ]. $8$ 

<sup>+</sup>*Spectroscopic data* for la: **1H** NMR (CDC13, 400 MHz) *6 5.56* (s, 2 was based on 2415 observed reflections *[I* > **3.00a(f)]** and 255 variable H), 7.22 (m, 6 H), 7.80 (m, 6 H); <sup>13</sup>C NMR (CDCl<sub>3</sub>, 100 MHz)  $\delta$  parameters with  $R(R_w) = 0.061(0.0092)$ . 127.7, 133.3, 143.6. For lb: **lH** NMR (CDC13, 400 MHz) 6 1.10 (s, 3 Atomic coordinates, bond lengths and angles, and thermal 127.7, 133.3, 143.6. For 1b: <sup>1</sup>H NMR (CDCl<sub>3</sub>, 400 MHz)  $\delta$  1.10 (s, 3<br>H), 5.53 (s, 1 H), 7.20 (m, 6 H), 7.67 (m, 3 H), 7.80 (m, 3 H); <sup>13</sup> NMR parameters have been deposited at the Cambridge Crystallographic<br>(CDCl<sub>3</sub>, (CDCl<sub>3</sub>, 100 MHz) δ -13.4, 127.3, 127.4, 131.4, 133.1, 144.2, 145.1.

 $\ddagger$  *Crystal data* for **lc**:  $C_{19}H_{16}OSi_2 \cdot 0.5H_2O$ ,  $M = 325.51$ , tetragonal cell, space group  $I4_1/a$ ,  $a = 28.162(7)$ ,  $c = 9.09(1)$  Å,  $V = 7211(9)$  Å<sup>3</sup>,  $Z = 16$ ,  $D_c = 1.199$  g cm<sup>-3</sup>,  $\mu = 1.93$  cm<sup>-1</sup>. The intensity data (20 < *55")* were collected on a Rigaku AFCSR diffractometer with graphite monochromated Mo-K $\alpha$  radiation ( $\lambda = 0.71069$  Å) and the structure was solved by direct methods. The non-hydrogen atoms were refined anisotropically. The final cycle of full-matrix least-squares refinement

The distance between the bridgehead Si atoms is 2.984(2) A, which is longer than Si-Si bond length in disilanes  $(2.33-2.37 \text{ Å})$ , but substantially shorter than the sum of van der Waals radius of silicon atoms  $(4.2 \text{ Å})$ ,<sup>9</sup> suggesting a possible through-space interaction between the bridgehead Si atoms; this is now under investigation.

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